

1/15

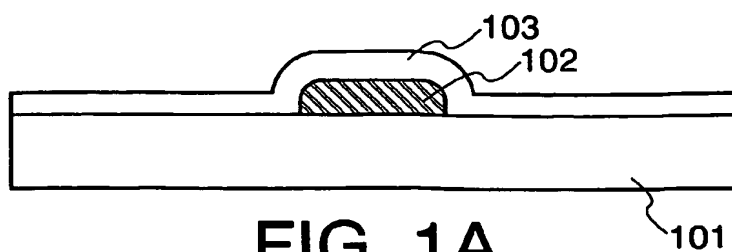


FIG. 1A

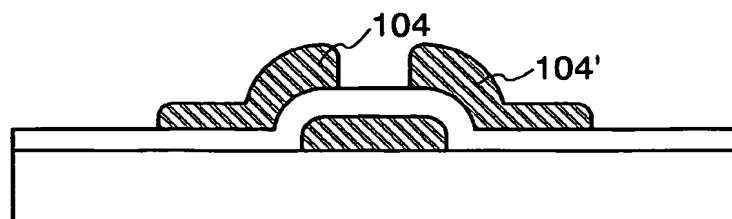


FIG. 1B

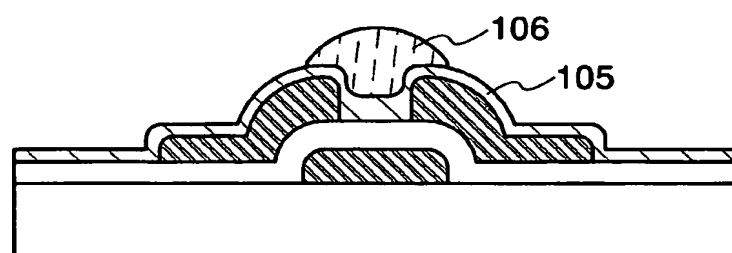


FIG. 1C

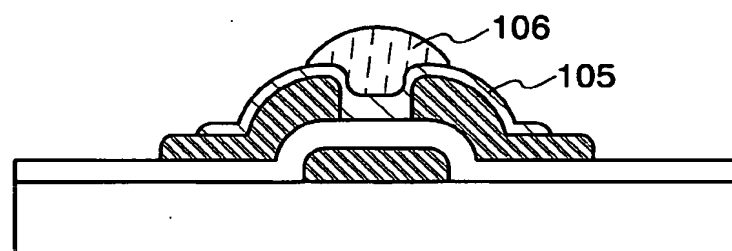


FIG. 1D

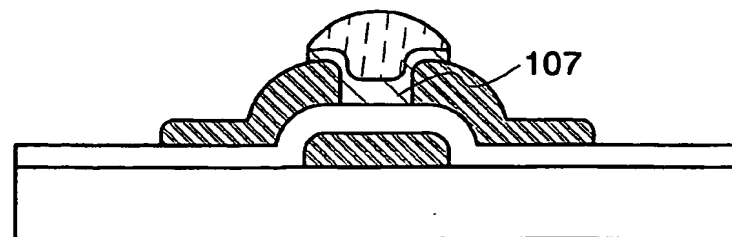


FIG. 1E

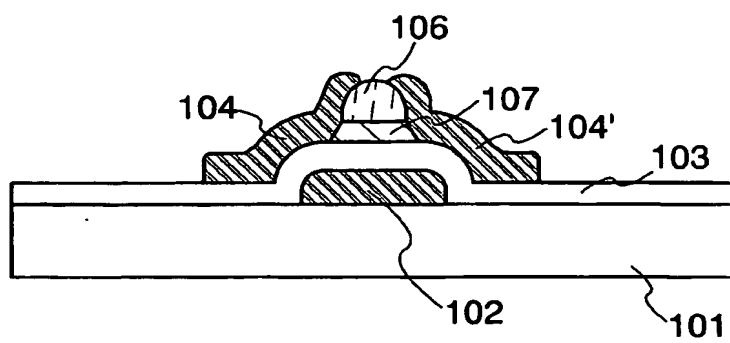


FIG. 2

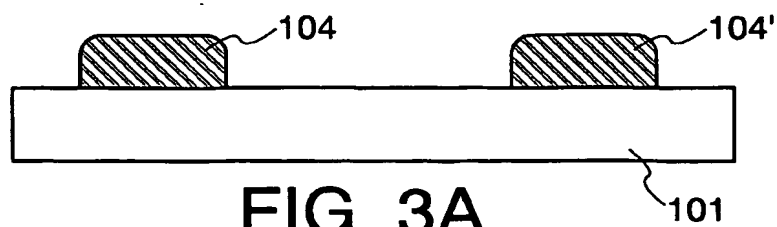


FIG. 3A

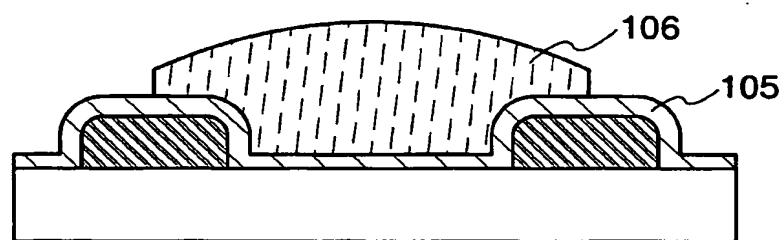


FIG. 3B

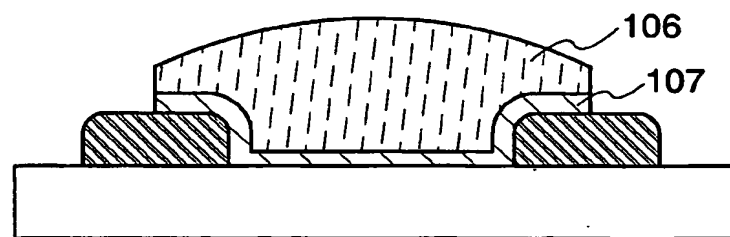


FIG. 3C

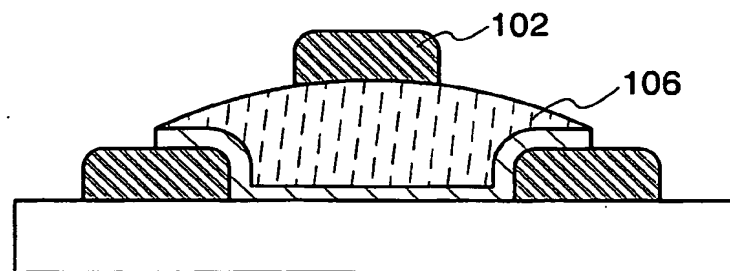


FIG. 3D

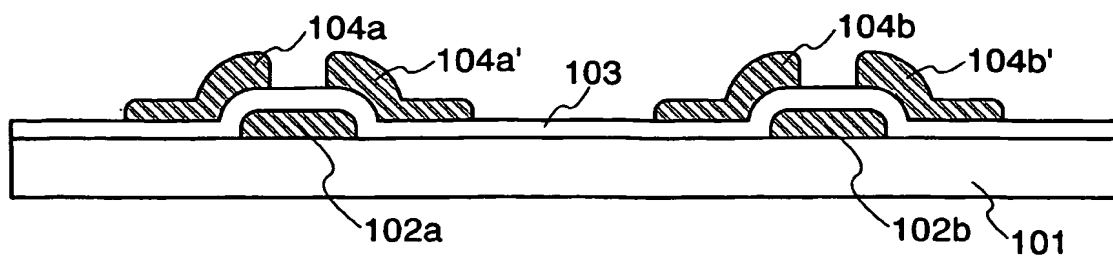


FIG. 4A

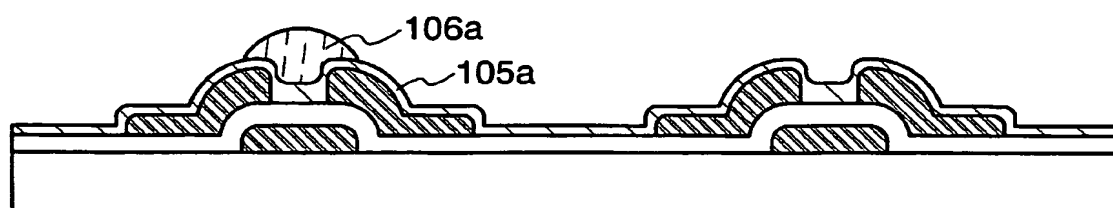


FIG. 4B

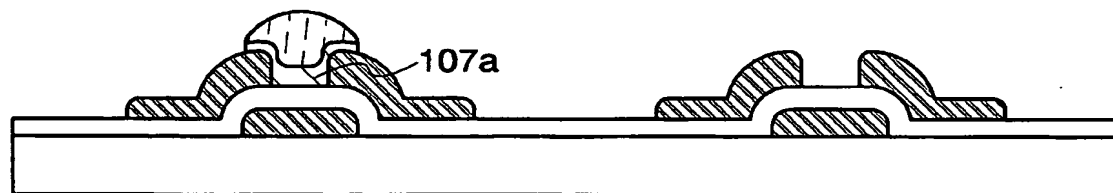


FIG. 4C

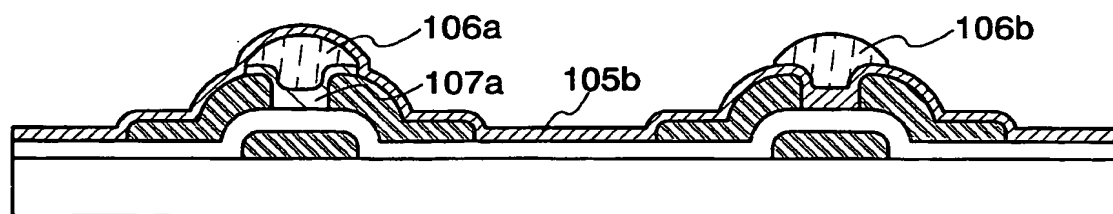


FIG. 4D

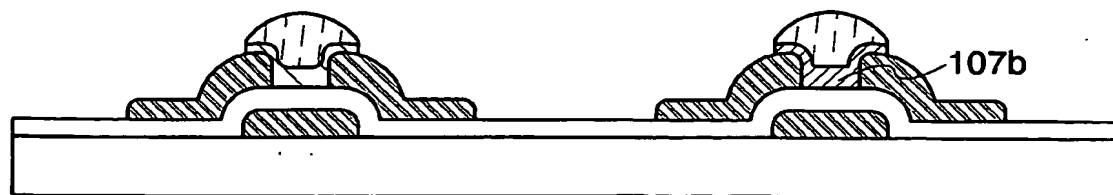


FIG. 4E

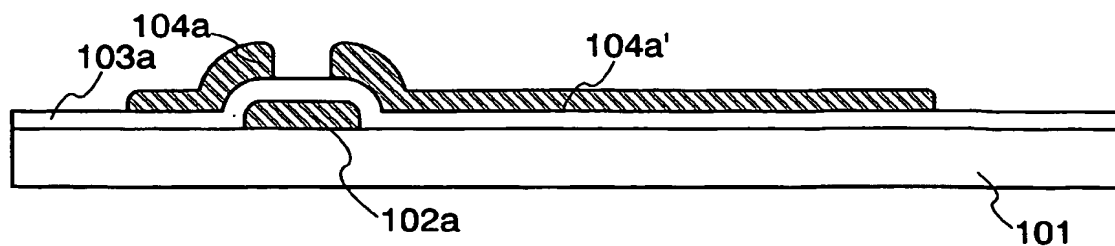


FIG. 5A

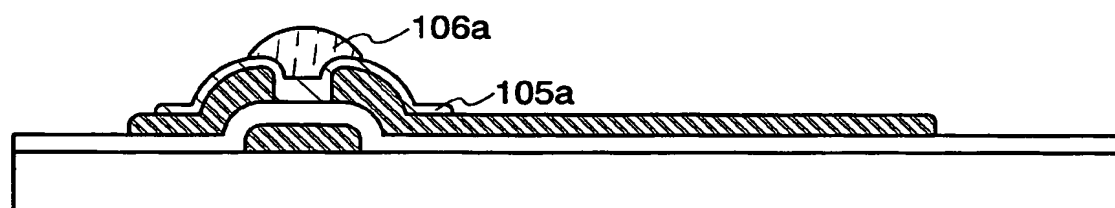


FIG. 5B

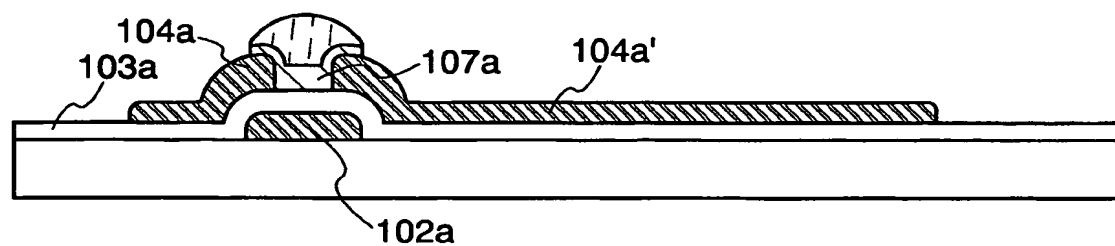


FIG. 5C

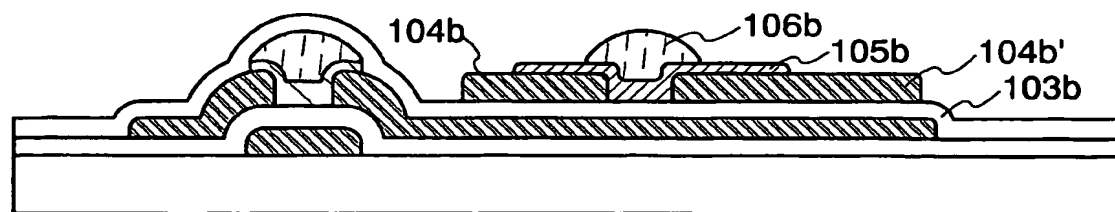


FIG. 5D

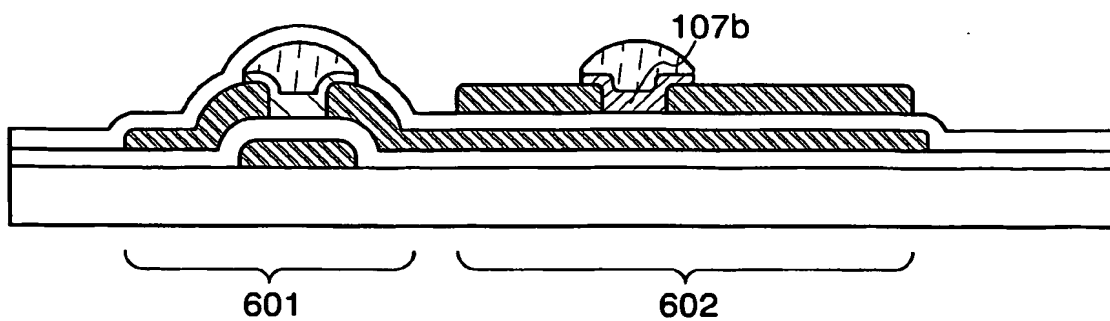


FIG. 6A

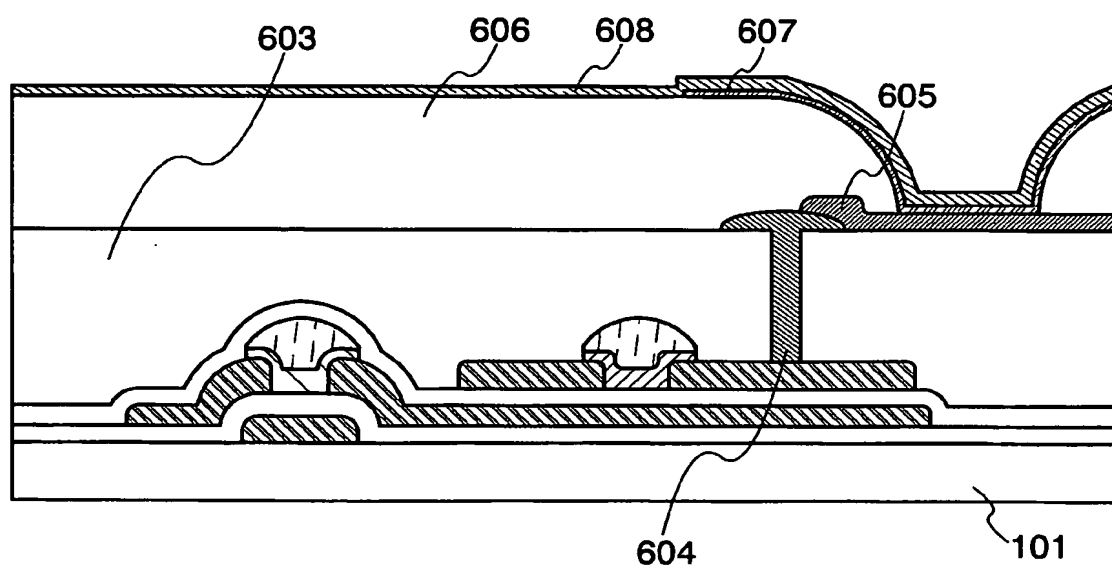


FIG. 6B

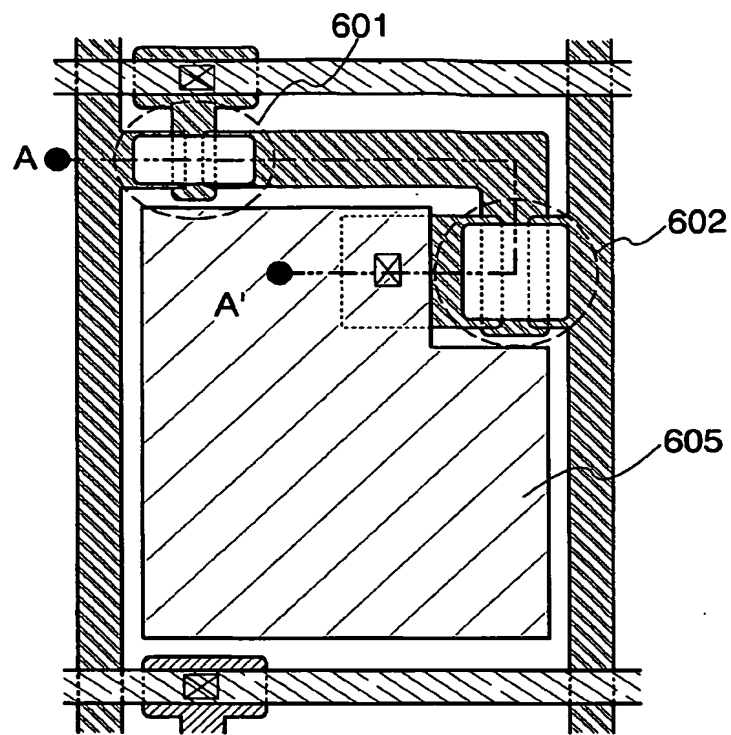


FIG. 7A

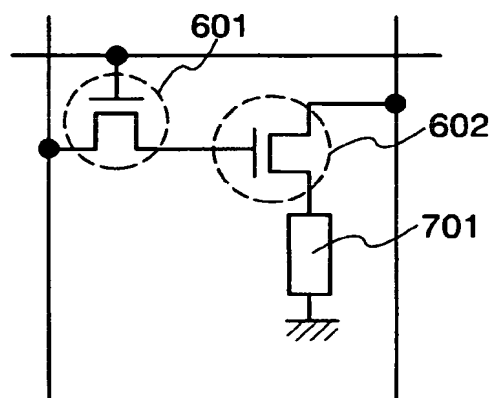


FIG. 7B

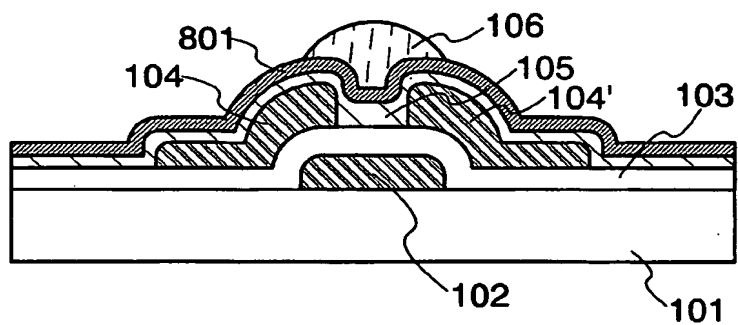


FIG. 8A

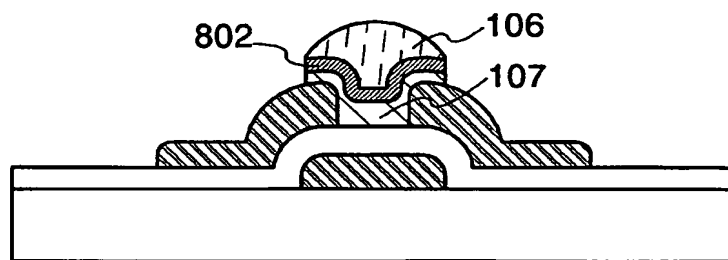


FIG. 8B

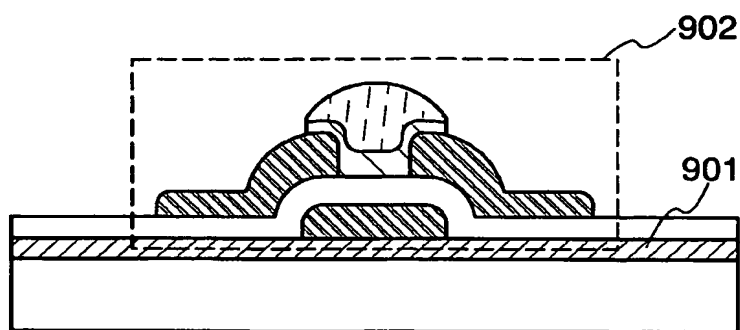


FIG. 9A

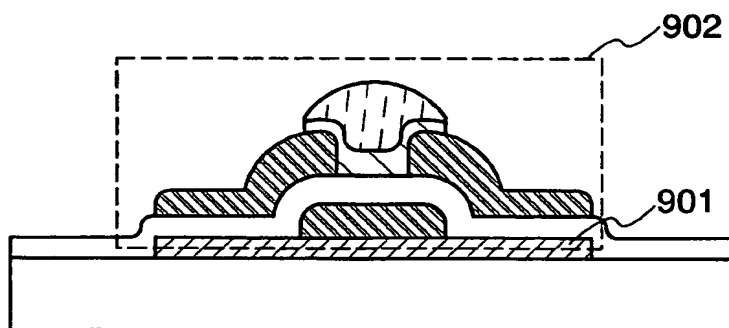


FIG. 9B

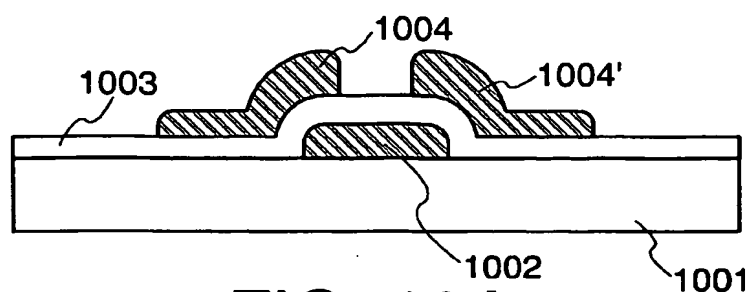


FIG. 10A

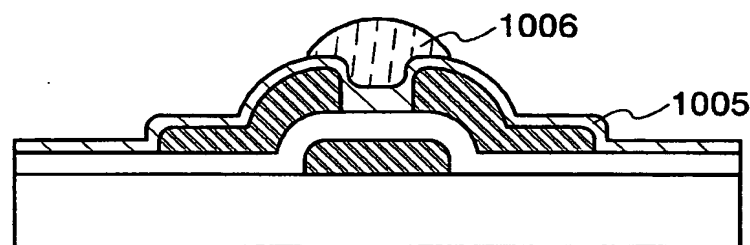


FIG. 10B

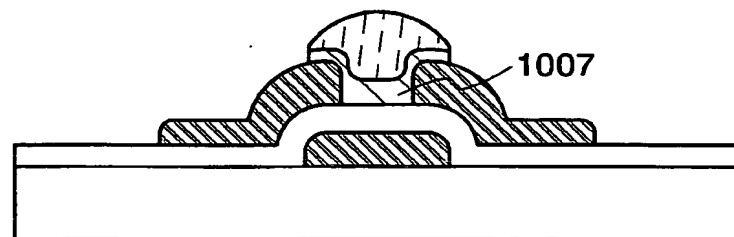


FIG. 10C

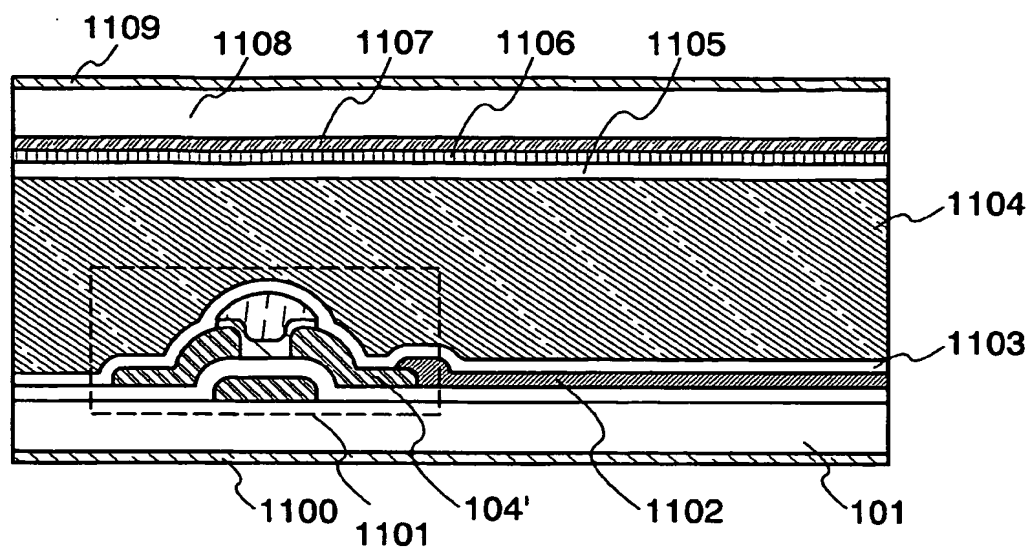


FIG. 11A

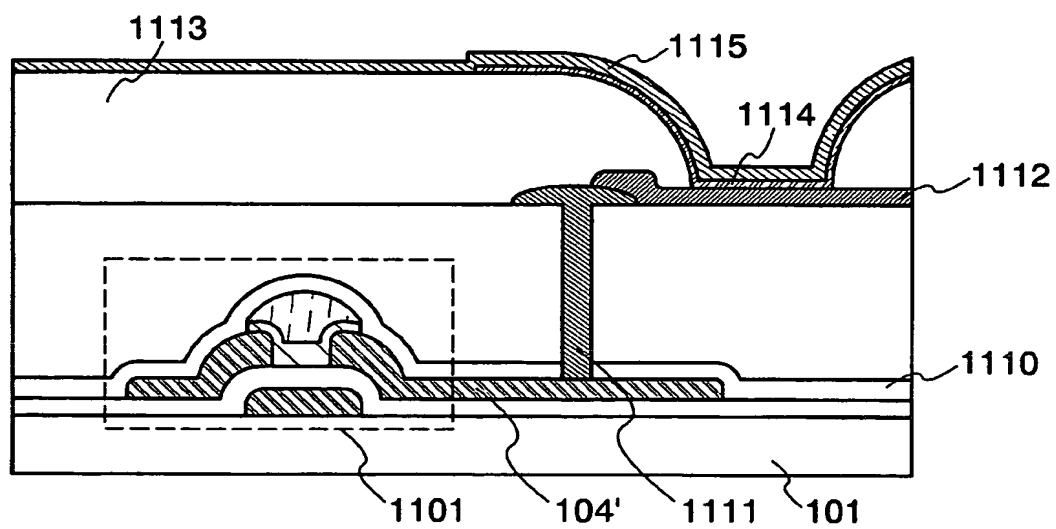


FIG. 11B

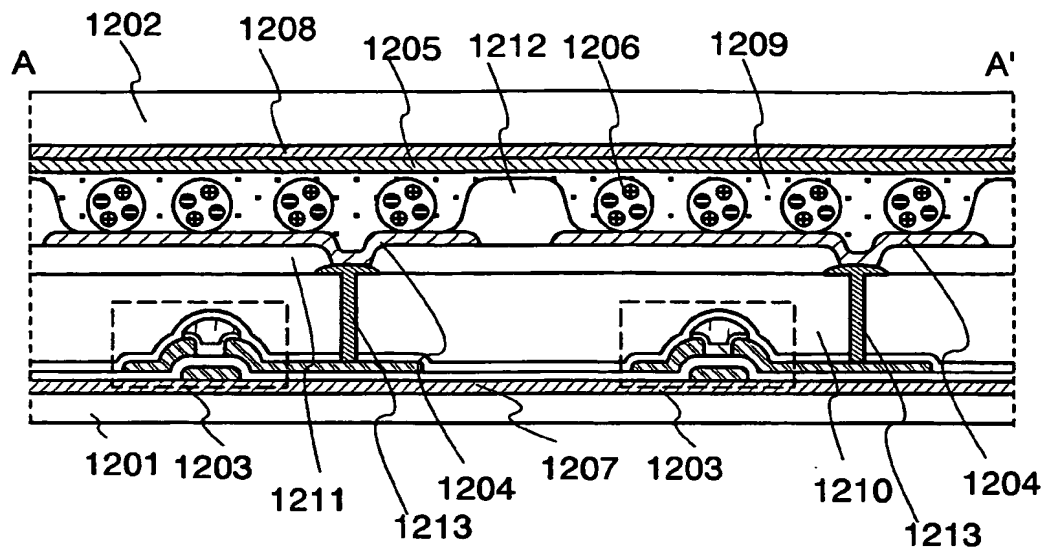


FIG. 12A

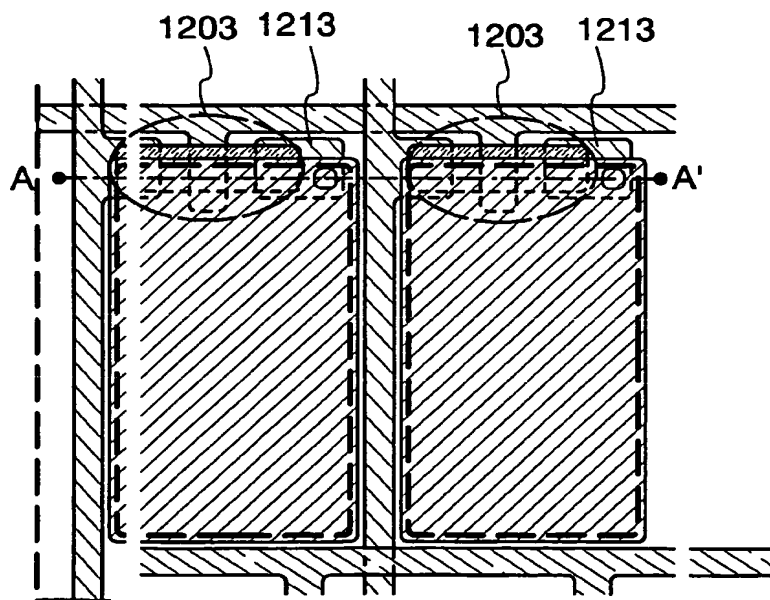


FIG. 12B

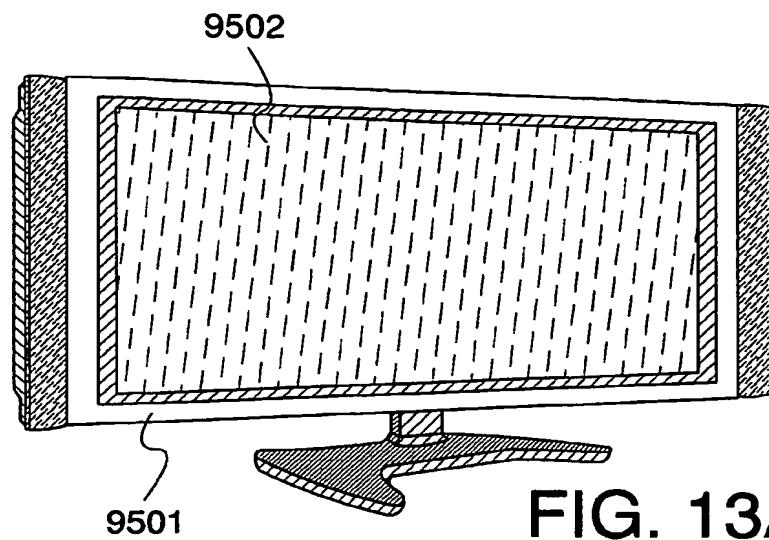


FIG. 13A

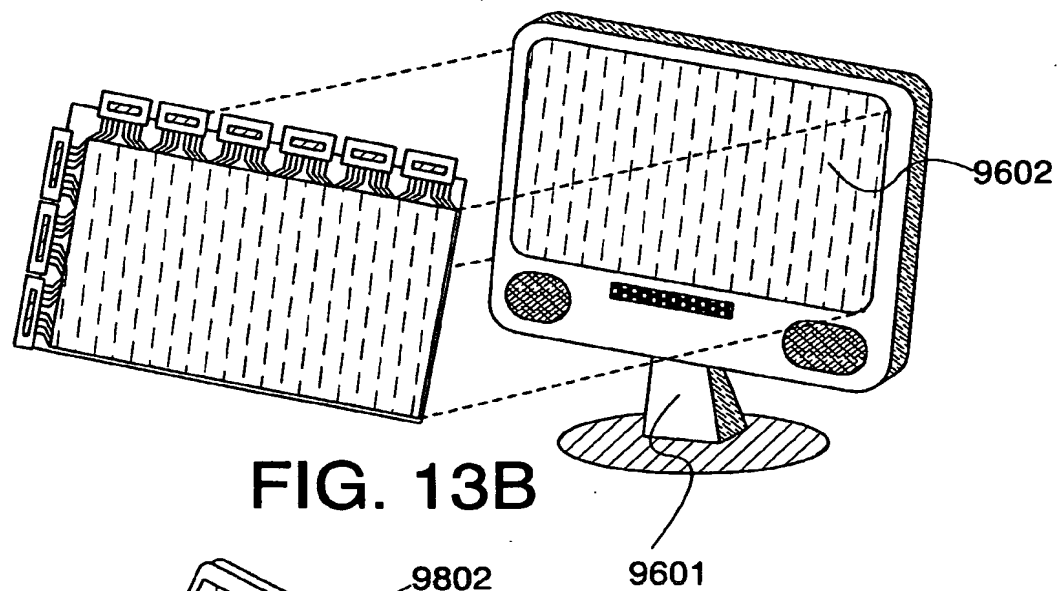


FIG. 13B

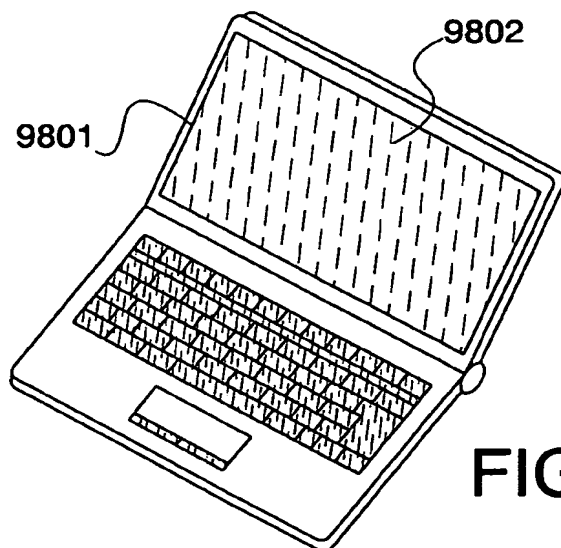


FIG. 13C

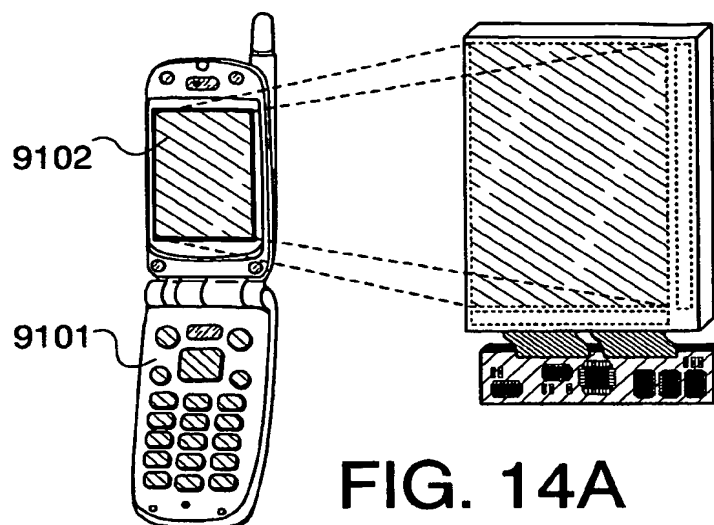


FIG. 14A

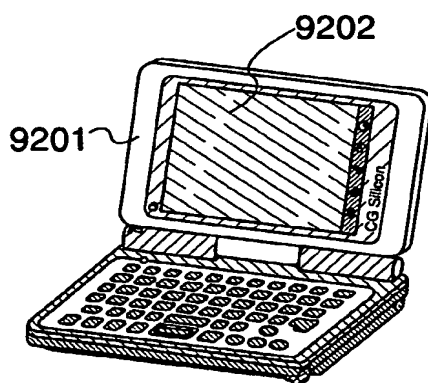


FIG. 14B

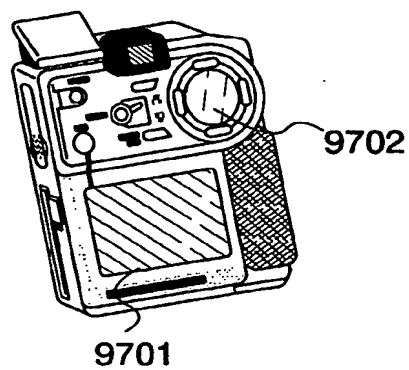


FIG. 14C

EXPLANATION OF REFERENCE

101: substrate, 102: gate electrode, 103: gate insulating film, 104: source electrode, 104': drain electrode, 105: semiconductor film, 106: mask, 107: semiconductor layer, 102a: gate electrode, 102b: gate electrode, 104a: source electrode, 104a': drain electrode, 104b: source electrode, 104b': drain electrode, 105a: first semiconductor film, 106a: first mask, 107a: semiconductor layer, 105b: second semiconductor film, 106b: second mask, 107b: semiconductor layer, 601: organic TFT, 602: organic TFT, 604: wiring, 605: conductive layer, 606: insulating layer, 607: electroluminescent layer, 608: conductive layer, 603: insulating film, 701: EL element, 801: inorganic film, 802: barrier layer, 901: barrier layer, 902: organic TFT, 1001: substrate, 1002: gate electrode, 1003: gate insulating film, 1004: source electrode, 1004': drain electrode, 1005: semiconductor film, 1006: mask, 1007: semiconductor layer, 1101: organic TFT, 1102: pixel electrode, 1103: orientation film, 1104: liquid crystal, 1105: orientation film, 1106: opposite electrode, 1107: color filter, 1108: substrate, 1109: polarizing plate, 1100: polarizing plate, 1110: insulating layer, 1111: wiring, 1112: conductive layer, 1113: insulating layer, 1114: electroluminescent layer, 1115: conductive layer, 1201: plastic substrate, 1203: organic TFT, 1204: pixel electrode, 1205: common electrode, 1206: microcapsule, 1207: barrier layer, 1209: electronic ink layer, 1210: insulating film, 1213: wiring, 9501: chassis, 9502: display portion, 9602: display portion, 9601: chassis, 9801: chassis, 9802: display portion, 9102: display portion, 9101, chassis, 9201; chassis, 9202: display portion, 9701: display portion, 103a: gate insulating film, 103b: gate insulating film, 1202: plastic substrate, 1208: barrier layer, 1211: insulating film, 1212: insulating film